HETEROEPITAXIAL GROWTH OF LiTaO₃ THIN FILMS BY PYROSOL PROCESS

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Highly oriented LiTaO₃ thin films were grown on (001) sapphire substrates by pyrosol process. X-ray diffraction analysis shows that the LiTaO₃ crystallite c-axis is normal to the sapphire substrate. X-ray pole figures reveal that the films are also in-plane oriented, with two components of heteroepitaxy, the main one being stabilized with the (110) axes of the layer parallel to the [110] direction of the substrate. Texture components are quantified.

Keywords: LiTaO₃ thin films; chemical vapour deposition; deposition process; pyrolysis; X-ray diffraction

INTRODUCTION

Because of their good piezoelectric and electrooptic properties, LiTaO₃-type ferroelectrics are technologically important for electrooptic, non-linear optical and surface acoustic waves devices. Thin films of LiTaO₃ have been formed by many physical and chemical routes, such as rf-magnetron sputtering [1], pulsed-laser deposition [2] and sol-gel methods [3, 4]. Recently, we reported the successful growth of polycrystalline LiTaO₃ layers on Si(111) substrates, and c-oriented LiTaO₃ layers on SiO₂-coated Si(111) and Al₂O₃ (006) substrates by

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pyrosol process. In this paper, we extend this work and provide additional insight into in-plane organization of the layers deposited on sapphire substrates.

EXPERIMENTAL

The experimental setup of the pyrosol process deposition has been described earlier. This system differs from conventional chemical vapour deposition system in its liquid delivery mechanism. An aerosol, generated by ultrasonic spraying of a precursor solution, is then conveyed by carrier gas near the surface of the heated substrates, giving rise to evaporation/pyrolysis process. A summary of the explored deposition conditions is presented in Table I. The crystallographic orientations of the films were determined by X-ray diffraction (θ/2θ spectra) and X-ray pole figure analyses. The used experimental set up, corrections for background, defocusing, absorption and volume variations were described earlier, so was the quantifying methodology for integration and volumic proportion calculations. The measurement of the full width at half-maximum (FWHM) of the rocking curves was also used as a measure of the crystalline quality of the films.

RESULTS AND DISCUSSION

At first, we examined the experimental parameters to obtain crystallized and oriented films of LiTaO₃ on (001) sapphire substrates.

<table>
<thead>
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<th>TABLE I</th>
<th>Deposition parameters</th>
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<tr>
<td>Solution Precursors:</td>
<td>lithium acetylacetonate 99% (LANCASTER)</td>
</tr>
<tr>
<td></td>
<td>tantalum ethoxide 99% (FLUKA)</td>
</tr>
<tr>
<td>Solvent:</td>
<td>Methanol</td>
</tr>
<tr>
<td>Concentration:</td>
<td>[Li] = 0.01 mol/l Li/Ta = 0.7</td>
</tr>
<tr>
<td>Spray parameters</td>
<td>Generator frequency: 800 kHz</td>
</tr>
<tr>
<td></td>
<td>Generator power: 90 W</td>
</tr>
<tr>
<td>Carrier gas</td>
<td>Rate: 1701/h – 1801/h</td>
</tr>
<tr>
<td></td>
<td>dry air</td>
</tr>
<tr>
<td>Substrates</td>
<td>sapphire Al₂O₃(006)</td>
</tr>
<tr>
<td>Temperatures:</td>
<td>550°C to 660°C</td>
</tr>
<tr>
<td>Growth rate:</td>
<td>10 – 12 nm/h</td>
</tr>
</tbody>
</table>
Because of their similar packing structure of atoms (Tab. II), highly oriented LiTaO$_3$ thin films can be expected to grow on Al$_2$O$_3$ substrates. However, the substrate temperature during deposition represents one of the most important parameters affecting the film morphology (homogeneity and thickness) and crystallinity (single crystal or polycrystal). At substrate temperatures below 600°C, polycrystalline layers are obtained without any detectable parasitic phases by X-ray diffraction. However, they already present a strong orientation along the (001) direction as shown by the high values of the $f(006)$ Lotgering factor [8] around 0.8. These $f$ values, calculated from the maximum intensities of the XRD patterns for the (001) direction, can be considered as a measure of the degree of orientation along the normal to the substrate. A multiple-step deposition process, involving the successive deposition of LiTaO$_3$ layers (and different cycles in temperature) can improve this degree of orientation. For a substrate temperature of 590°C, it rises from 0.82 for a one-step deposition of 8 hours (Fig. 1a) to 0.86 for a two-steps deposition of 2×8 hours (Fig. 1b), showing that the quality of the film depends, to a large extent, on the physical properties of the underlaying substrate.

X-ray diffraction patterns for films grown at substrate temperatures above 600°C show only peaks belonging to (001) LiTaO$_3$, indicating that a strong preferential orientation with the {001} lithium tantalate planes parallel to the {001} sapphire ones (Fig. 2) is stabilized. A little substrate misorientation (during X-ray experiments) explains why we observe the X-ray peak of the substrate in the spectrum presented in Figure 2. Rocking curve analyses are consistent with improved crystallinity when the temperature is increased (Fig. 3). Furthermore, for a given temperature in the range 600°C–650°C, the use of a multiple-step deposition process allows a significant decrease of the FWHM around 0.3°, carrying out the proof of an improved quality of

<table>
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<tr>
<th>TABLE II</th>
<th>Structure and lattice parameters of LiTaO$_3$ and Al$_2$O$_3$ (data from ASTM standards)</th>
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</thead>
<tbody>
<tr>
<td>Structure</td>
<td>Space group</td>
</tr>
<tr>
<td>LiTaO$_3$</td>
<td>Hexagonal (rhombohedral)</td>
</tr>
<tr>
<td></td>
<td>a$_H$ = 5.154 Å, c$_H$ = 13.755 Å</td>
</tr>
<tr>
<td></td>
<td>(a$_R$ = 5.474 Å, $\alpha_R$ = 56°10.5')</td>
</tr>
<tr>
<td>Al$_2$O$_3$</td>
<td>Hexagonal (rhombohedral)</td>
</tr>
<tr>
<td></td>
<td>a$_H$ = 4.758 Å, c$_H$ = 12.991 Å</td>
</tr>
<tr>
<td></td>
<td>(a$_R$ = 5.12 Å, $\alpha_R$ = 56°17')</td>
</tr>
</tbody>
</table>
FIGURE 1 X-ray diffraction patterns and (006) rocking curve insert of LiTaO$_3$ thin films deposited at 580°C on a c-oriented sapphire substrate, with initial liquid concentration of [Li] = 0.01 mol/l and Li/Ta = 0.7 (a) one-step deposition process (b) two-steps deposition process. Intensity scale is shifted for a better visualization of (a) and (b) spectra.

the as-grown films. The sapphire substrate, by itself, has a 0.2° FWHM for the same geometry. The larger the thickness of the layer is (i.e., the less the substrate influences the layer), the better the crystalline quality and the homogeneity are. The systematic improvement of the crystalline quality of the films with their thickness implies that the surface of the latter becomes less defective, and hence a more effective template for epitaxy. This result is consistent with previously published results on LiTaO$_3$ thin films grown on Al$_2$O$_3$ substrates by pulsed laser deposition. [9] The lower quality of the near interface region is likely related to the misfit dislocations arising from a lattice mismatch of about 8%.

X-ray pole figures were measured by the reflection technique [10] and projected on the surface of a sample elaborated in optimized
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conditions. They confirm the strong preferred orientations of the crystallites and they reveal heteroepitaxial relationships (Fig. 4). We investigated a 150-nm thick LiTaO$_3$ thin film grown on a c-oriented sapphire substrate. The position of the pole in the \{006\} pole figure, well centered, shows that all the crystallites have their c-axes perpendicular to the surface of the sample, thus parallel to the c-axis of the substrate (c$_\perp$ orientation). \{012\} and \{104\} pole figures reveal strong in-plane orientation of the layer: most of the crystallites have their \langle110\rangle direction parallel to the [110] direction of the substrate, as shown by the high value of the pole density. For the \{012\} pole figure, we found $D^\text{max}_{012}$ around 350 m.r.d. (multiple of a random distribution). However, we can identify two sets of poles, 60°-rotated one with respect to the other around their c-axes, evidencing two symmetrical in-plane orientations of the crystallites. In addition to the three poles of the dominant orientation that overlap with the substrate,
FIGURE 3 FWHM of the (006) rocking curve with respect to sapphire substrate temperature and deposition process.

FIGURE 4 {006}, {012} and {104} pole figures of a 150-nm thick LiTaO₃ thin film synthesized by a three-steps deposition process on a c-oriented sapphire substrate, at 610°C, with initial liquid concentration of [Li]=0.01 mol/l and Li/Ta =0.7. Equal area projections, logarithmic intensity scale. (See Color Plate I).

the sample shows three weaker poles (Fig. 5). The volumic ratio of crystallites of each orientation is not equal, the major orientation c_{100} being in exact alignment with the substrate. Figure 6 is a detailed view of the {012} pole figure of the same sample represented as a series of
FIGURE 5 Detailed schema of the (012) pole figure of the Figure 4.

\( \varphi = 0 \)

[110] Al\(_2\)O\(_3\)

<110>\(_1\) LiTaO\(_3\)

\( \varphi \sim 17\% \)

\( \varphi \sim 83\% \)

\( \chi \)

\( c_{\perp 0} \)

\( c_{\perp 60} \)

\( \sim 17\% \)

\( \sim 83\% \)

\( \varphi \)-scans. The horizontal and depth axes are respectively the \( \varphi \) and \( \chi \) angles (\( 0 \leq \varphi \leq 360^\circ \), \( 44^\circ \leq \chi \leq 72^\circ \)) while the vertical axis represents the diffraction intensity normalized to the maximum value. This graph reveals clearly the respective contributing intensities of the \( c_{\perp 0} \) and \( c_{\perp 60} \) components. After integration of each pole intensity and average of the three poles for each component, we found \( 83 \pm 2\% \) of \( c_{\perp 0} \), relative to the total volume of the presented sample. We estimated the deviation by integration over the zero-intensity ranges of the corrected pole figure on the same angle range as the poles. The angular dispersions are limited to \( 4.5^\circ \) in \( \chi \) and \( 4^\circ \) in \( \varphi \) at 15% of the maximum intensity. Thus, the sample exhibits a rather small mosaicity compared to usually grown ferroelectric materials such as perovskites \(^{111}\) and the method of elaboration provides a texture of good quality even if in-plane misorientations are present.

Different assumptions can be expressed to understand these results. On one hand, the nucleation of the two variants described above can be explained as follows. The crystal structure for both lithium tantalate and sapphire can be visualized, along the \( c \)-axis direction, as a succession of oxygen octahedra with two thirds octahedral sites occupied by cations and the remaining one third left vacant. Figure 7
shows a top view of the \{00l\} planes of LiTaO$_3$ and Al$_2$O$_3$. The nucleation of lithium tantalate on this surface can occur by either the lithium or the tantalum atoms placed in the vacant octahedral sites. Since both lithium tantalate and sapphire are rhombohedral (threefold symmetry), the two placements of lithium and tantalum can create orientations rotated by 60° with respect to one another. Thus, the growth from the two different nuclei results in two crystallographic variants in the film. On the other hand, the minor texture component could be provided by crystallites oriented with their c-axes in the opposite direction as those from the major component. In other words, the two crystallographic variants could be compared to parallel and anti-parallel domains. Then, a ratio of nearly 50% of $c_{\perp 0}$ would
cancel any chance to observe piezoelectric properties, the $c$-axis direction being the polar-axis direction in this material. Thus, as the contribution of the two sets of poles is rather different, our strongly oriented LiTaO$_3$ thin films could be sufficiently piezoelectric to form SAW filters, although strictly single crystalline films would be suitable.

**CONCLUSION**

In summary, we have succeeded in growing strongly $c$-oriented thin films of single phase LiTaO$_3$ by pyrosol process. The as-grown LiTaO$_3$ layers exhibit a strong in-plane orientation with two components of different volumic ratio, thus showing good potentiality as new materials alternative in SAW devices.

**Acknowledgements**

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References